	Туре	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	122094	interconnect\$4 or plug\$4 or trench\$4 or damascene	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 10:22
2	BRS	L2	216699	tungsten or W or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?"	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 13:48
3	BRS	L3	343303	plat\$4 or electroplat\$4 or ECD or (electro\$6 adj copper adj deposit\$6)	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 10:25
4	BRS	Table 1	117594	1 and 2 and 3	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 10:26
5	BRS	L5	3751	1 same 2 same 3	USPAT; US-PG US-PG; EPO; DPO; DERWE NT; IBM_T DB	2003/11/18 10:57

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	Туре	L#	Hits	Search Text	DBs	Tim Stamp
6	BRS	L6	516239	(2 not seed\$3) and 3	JPO; DERWE NT; IBM_T DB	2003/11/18 10:29
7	BRS	L7	3210	(2 not seed\$3) and 5		2003/11/18 10:29
8	BRS	L8	309366 8	need or redundant or eliminat\$4 or obviat\$4 or superfuous\$4 or unneccessary\$4	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 10:35
9	BRS	<b>L</b> 9	2040	7 and 8	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 10:35
10	BRS	Llo	271	9 and damascene	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 10:36

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	Type	L #	Hits	Search Text	DBs	Time Stamp
11	BRS	L11	385	1 near8 2 near8 3	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 10:58
12	BRS	L12	6065	barrier near2 (layer or film) with 2	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 13:50
13	BRS	L13	1470	12 with 1		
14	BRS	L14	59	13 with 3	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T	2003/11/18 13:51

	Туре	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	Ll	122094	interconnect\$4 or plug\$4 or trench\$4 or damascene	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:18
2	BRS	L2	216699	tungsten or W or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?"	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:18
3	BRS	L3	343303 3	plat\$4 or electroplat\$4 or ECD or (electro\$6 adj copper adj deposit\$6)	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:18
4	BRS	L4	117594	(tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:18
5	BRS	<b>L</b> 5	3751		USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:18

	Туре	L #	Hits	Search Text	DBs	Time Stamp
6	BRS	L6	516239	((tungsten or W or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?") not seed\$3) and (plat\$4 or electroplat\$4 or ECD or (electro\$6 adj copper adj deposit\$6))	FUD;	2003/11/18 17:18
7	BRS	<b>L</b> 7	3210	((tungsten or W or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?") not seed\$3) and ((interconnect\$4 or plug\$4 or trench\$4 or damascene) same (tungsten or W or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?") same (plat\$4 or ECD or (electro\$6 adj copper adj deposit\$6)))	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:18
8	BRS	<b>L</b> 8	309366 8	need or redundant or eliminat\$4 or obviat\$4 or superfuous\$4 or unneccessary\$4	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:19

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	Typ	L#	Hits	Search Text	DBs	Tim Stamp
9	BRS	L9	2040	(((tungsten or W or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WS:N.sub.?") not seed\$3 and ((interconnect\$4 or plug\$4 or trench\$4 or damascene) same (tungsten or W or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?") same (plat\$4 or ECD or (electro\$6 adj copper adj deposit\$6))) and (need or redundant or eliminat\$4 or obviat\$4 or superfuous\$4 or unneccessary\$4)	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:19
10	BRS	L11	385	(interconnect\$4 or plug\$4 or trench\$4 or damascene) near8 (tungsten or W or (tungsten adj nitride) or "WNN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?") near8 (plat\$4 or electroplat\$4 or ECD or (electro\$6 adj copper adj deposit\$6))	JPO;	2003/11/18 17:19
11	BRS	L12	6065	barrier near2 (layer or film) with (tungsten or W or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?")	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:19
12	BRS	L13	1470	(barrier near2 (layer or film) with (tungsten or W or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?")) with (interconnect\$4 or plug\$4 or trench\$4 or damascene)	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:19

	Туре	L #	Hits	Search Text	DBs	Time Stam
13	BRS	L10	271	same (plat\$4 or ECD or	DERWE NT; IBM_T DB	2003/11/18 17:19
14	BRS	L14	59	or (tungsten adj nitride) or "WN.sub.?" or (tungsten adj silicon adj nitride) or "WSiN.sub.?")) with (interconnect\$4 or plug\$4 or trench\$4 or damascene))	USPAT; US-PG PUB; EPO; JPO; DERWE NT; IBM_T DB	2003/11/18 17:19

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	206390	electrolyte\$3	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:42
2	BRS	L2	105947	electrochem\$6	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:44
3	BRS	L3	29566	1 same 2	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:44
4	BRS	L4	8647	damascene\$3	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:43
5	BRS	L5	217061 3	W or tungsten or WN or Wsin or "WN.sub.?" or "WSiN.sub.?"	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20

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	Туре	L #	Hits	Search Text	DBs	Tim Stamp
6	BRS	L6	821	3 same 5	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:44
7	BRS	L7	16	6 and 4	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:44
8	BRS	L8	16489	1 near8 2	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:44
9	BRS	L9	2687	electrochem\$6 near4 reduc\$6 near4 oxid\$8	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:46
10	BRS	Llo	889	1 same 9	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:45

	Type	L #	Hits	Search Text	DBs	Time Stamp
11	BRS	L11	20	10 same 5	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:46
12	BRS	L12	3929	electrochem\$6 near8 reduc\$6 near8 oxid\$8	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:46
13	BRS	L13	114	12 same 5	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 11:47

	Туре	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L11	206390	electrolyte\$3	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:49
2	BRS	L12	105947	electrochem\$6	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20
3	BRS	L13	29566	electrolyte\$3 same electrochem\$6	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20
4	BRS	L14	8647	damascene\$3	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:31
5	BRS	L15	217061	W or tungsten or WN or Wsin or "WN.sub.?" or "WSiN.sub.?"	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:32

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	Туре	L #	Hits	Search Text	DBs	Time Stamp
6	BRS	L16	821	(electrolyte\$3 same electrochem\$6) same (W or tungsten or WN or WsiN or "WN.sub.?" or "WSiN.sub.?")	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:31
7	BRS	L17	16	((electrolyte\$3 same electrochem\$6) same (W or tungsten or WN or WsiN or "WN.sub.?" or "WSiN.sub.?")) and damascene\$3	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20
8	BRS	L18	16489	electrolyte\$3 near8 electrochem\$6	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20
9	BRS	L19	2687	electrochem\$6 near4 reduc\$6 near4 oxid\$8	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:44
10	BRS	L20	8 8 9	electrolyte\$3 same (electrochem\$6 near4 reduc\$6 near4 oxid\$8)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:31

	Type	L #	Hits	Search Text	DBs	Time Stamp
11	BRS	L21	20	(electrolyte\$3 same (electrochem\$6 near4 reduc\$6 near4 oxid\$8)) same (W or tungsten or WN or WsiN or "WN.sub.?" or "WSiN.sub.?")	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:31
12	BRS	L22	3929	electrochem\$6 near8 reduc\$6 near8 oxid\$8	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	
13	BRS	L23	114	(electrochem\$6 near8 reduc\$6 near8 oxid\$8) same (W or tungsten or WN or WsiN or "WN.sub.?" or "WSiN.sub.?")	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:32
14	BRS	L24	217061 3	W or tungsten or WN or WsiN or "WN.sub.?" or "WSiN.sub.?" or (tungsten adj nitride) or (tungsten adj silicon adj nitride)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:33
15	BRS	L25	84	19 same 24	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20

	Туре	L #	Hits	Search Text	DBs	Time Stam
16	BRS	L26	114	22 same 24	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:34
17	BRS	L28	25	26 same 11	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	
18	BRS	L29	89	26 not 28	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	
19	BRS	ray o	0	29 and 14	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:38
20	BRS	L31	22707	11 with 12	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD	2003/11/20 13:39

	Туре	L #	Hits	Search Text	DBs	Time Stamp
21	BRS	L32	217	31 with 24	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:39
22	BRS	L33	122198	interconnect\$4 or plug\$4 or trench\$4 or damascene\$3	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:40
23	BRS	L34	35	32 and 33	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:40
24	BRS	L35	2	19 with 11 with 33	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:46
25	BRS	L36	<b>5</b>		USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:48

	Тур	L #	Hits	Search Text	DBs	Time Stamp
26	BRS	L37	1202	11 same 22	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:49
27	BRS	L38	25	37 same 24	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:50
28	BRS	L39	3	38 and 33	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:50
29		L40	9700	electrochem\$6 same reduc\$6 same oxid\$8	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:51
30	BRS	L41	3370	11 same 40	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:52

	Туре	L #	Hits	Search Text	DBs	Time Stamp
31	BRS	L42	72	41 same 33	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:52
32	BRS	L43	113	41 same 24	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:52
33	BRS	L44	34	43 and 33	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD	2003/11/20 13:55
34	BRS	L45	31	12 near8 33 near8 11 near8 oxid\$8	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2003/11/20 13:56

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chemical-interdiffusion; conformal-coatings; copper; current-density; diffusion-barriers; electricresistance; electroplating; integrated-circuit-interconnections; integrated-circuit-metallisation.

#### Keyw rds

sheet resistance effects; electroplating; copper; seedless barrier films; metal resistance controlled plating current distribution; circular wafers; uniform metal film electro deposition; resistive film; copper plating solutions; uniform film deposition; Ta barrier layers; resistive metal barrier layers; plating current density; uniformity characterization; dimensionless polarization parameter; current density; chemical properties; physical properties; Cu plating; plating exchange current density; copper concentration; plating bath; uniform conformal conduction layer; electro deposition; bulk copper film plating rate; 500 angstrom; 200 mm; Cu Ta; Cu.

## Classification codes

```
B2550F
         (Metallisation and interconnection technology).
B0520J
         (Deposition from liquid phases).
B2570
         (Semiconductor integrated circuits).
B2530D
         (Semiconductor-metal interfaces)
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# Chemical indexing

Cu-Ta int, Cu int, Ta int, Cu el, Ta el; Cu int, Cu el.

## Numerical indexing

size: 5.0E-08 m. 2.0E-01 m.

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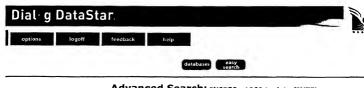
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